

### LASER HEATED DISCHARGE PLASMA

Increased EUV emission and change in plasma parameters

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Detlev Grützmacher, Larissa Juschkin

RWTH Aachen University and Forschungszentrum Jülich



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### **MOTIVATION**

#### **Discharge based EUV generation**

#### Conventional gas discharge source

- Electric field ionized gas at low pressure
- Stored electric or magnetic energy is discharged through plasma
- Plasma compressed to a pinch confined by own magnetic field
- Hot pinch emits EUV (cooling)

#### Adjustable parameters:

- Gas type/pressure (flow)
- Discharge energy
- Geometry
- Electrical system





### **MOTIVATION**

#### **Discharge based EUV generation and laser heating**

#### Laser heated discharge source

- Discharge source as target delivery system
- Compressed pinch as target
- Heating by laser pulse

#### **Possible advantages:**

- Restore energy loss from radiative cooling
- Prolong pulse duration
- Increase EUV output
- Stabilize discharge
- Higher radiance





### THEORY

#### Laser plasma interaction

#### Inverse electron-ion bremsstrahlung -

Absorption coefficient<sup>1</sup>:

$$\alpha \propto c_0 \frac{n_e^2}{n\omega_L^3} \cdot \sqrt{\frac{c_1}{T_e}} \cdot \left(1 - exp\left(-c_2 \frac{\omega_L}{T_e}\right)\right) \cdot \overline{g}$$

Gaunt factor:  $\overline{g} \propto \sqrt{c_3 \frac{T_e}{\omega_L}}$ 

Refraction —

Dielectric permittivity: 
$$\varepsilon = 1 - \frac{\omega_P^2}{\omega_L^2} = n^2$$
  
with  $\omega_P = \sqrt{\frac{n_e e^2}{\varepsilon_0 m_e}}$ 

[1] S. Brückner, S. Wieneke and W. Viöl, "Generation of Double Pulses in the Extreme Ultraviolet Spectral Range Using a Laser Combined Pinch Plasma Source", The Open Plasma Physics Journal, 2009, 2, 17-23

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### **EXPERIMENTAL SETUP**

Plasma source

#### Laser heated discharge source

#### Gas discharge source

- Voltage: 2 kV
- Energy: 2.2 J
- Pulse duration 100 ns
- Gases: Xe, Ar, O<sub>2</sub>, N<sub>2</sub>

### CO<sub>2</sub>-TEA Laser

- Wavelength: 10.6 µm
- Pulse duration: 100 ns
- Energy <1 J/pulse</li>
  →Courtesy of ASML



### **EXPERIMENTAL SETUP**

#### **Custom trigger design**

- Special hollow cathode trigger to enable outcoupling of laser beam
- Blocking potential

 $\rightarrow$  Inhibits discharge at high gas flow

• Active flashover ignition

 $\rightarrow$  Very low jitter of discharge timing (<10 ns)









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#### Xenon time sweep Reflection at Laser scattered at electrode plasma Slight increase Photograph at ~5° 1.5 1.5 1.0 1.0 IR 10.6µm EUV 10-20nm 1.0 -1.0 0.8 - 0.8 0.5 -0.5 -0.6 - 0.6 laser mm mm 0.0 0.0 0.4 - 0.4 -0.5 --0.5 -- 0.2 - 0.2 -1.0 --1.0 front back front back laser 0.04 -1.50.0 -1.5-2 $^{-1}$ 0 1 2 -2 $^{-1}$ 0 1 2 mm mm 0.4 Xenon 10 sccm at 2 kV • 0.2 intensity a.u. 600 mJ laser pulse • 0.0 100 shot average dl/dt • PVM100 back Viewing angle 13° -0.2 PVM100 front EUV diode Quenched transmission -0.40.3 0.0 0.1 0.2 0.4 0.5 -0.1time in us





#### Xenon time sweep



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#### **Strongest effect in Xenon**



- Xe 10 sccm at 2 kV
- 600 mJ laser pulse
- 100 shot average
- Viewing angle 13°
- ✓ >2x peak intensity
- ✓ Increased emission volume
- ✓ Prolonged pulse
- ✓ No transmission of laser pulse



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#### Strongest effect in Argon



- Ar 20 sccm at 2 kV
- 600 mJ laser pulse
- 100 shot average
- Viewing angle 13°
- ✓ ~2x peak intensity
- ✓ Increased emission volume
- ✓ Prolonged pulse
- ✓ No transmission of laser pulse



### **SPECTRA**

no laser

laser

Ar VIII

Ar VII

Ar VIII

15.0

50

17.5

12.5

intensity in a.u.

1.0

0.5

0.0

gain factor

3

2

1

0

#### Influence of synchronization

• Higher ionization levels show more gain

Argon 20 sccm

22.5

wavelength in nm

At pinch

150

delay in ns

25.0

200

27.5

250

- Later timing affects lower levels more
- Maximum when synched to pinch

20.0



100

### **SPECTRA**

#### Influence of laser pulse energy

- Laser pulse energy at 100% = 800 mJ ullet
- Synched to pinch
- Gain saturates differently for different ion. levels



0.4

0.2

-0.2

-0.4

-0.1

dl/dt PVM100 back

PVM100 front EUV diode

0.0

0.1

0.2

time in us

0.3

0.4

0.5

intensity a.u. 0.0

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## **PINCH PROFILE – XENON**

#### **Tomographic reconstruction**

- 3d-reconstruction exploits rotational symmetry
- Input: Spatially resolved spectra at different angles

#### Result:

- RZ-profile of plasma at arbitrary wavelength
- Xe<sup>10+</sup> moves to front
- Xe<sup>8+</sup> shifts back

Rotatable

spectrometer



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## **PINCH PROFILE – ARGON**

#### **Tomographic reconstruction**

- 3d-reconstruction exploits rotational symmetry
- Input: Spatially resolved spectra at different angles

#### Result:

- RZ-profile of plasma at arbitrary wavelength
- Expanded emission region at front as seen in pinhole images





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### **PLASMA PROPERTIES**

#### Temperature and density analysis for Argon



- Regularized linear least squares fit of selected peaks (POI)
- Resonance peaks ignored
  → self absorption/opacity
- Composition sensitive
- Plasma physics computations beforehand, not at runtime → fast
- Based on ChiantiPy

#### <sup>2</sup> <u>Ar at 20 sccm</u>

- ✓ Reaches optimum density
- for laser absorption (I)
- ✓ Background pressure resolved (I)
- ✓ ~3 eV temp. increase



### **FDTD-SIMULATION**

#### Laser absorption and refraction

- 2d-finite difference time domain simulation with MEEP
- Absorption coefficient from inverse electron-ion bremsstrahlung
- Re[ɛ] from electron density (plasma frequency) in mm
- $n_{e max} = 10^{18.3} \text{ cm}^{-3}$  ,  $T_e = 30 \text{ eV}$

#### Result:

- $\rightarrow$  Energy absorbed at front
- $\rightarrow$  Laser is refracted by plasma
- Experiment:
- Front part of pinch is heated
- ✓ Back part is unaffected
- ✓ No transmission observed, even with under-dense plasma



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in mm

### SUMMARY AND OUTLOOK

#### Laser heating

- ✓ Increases EUV output (up to 700%)
- ✓ Hotter plasma (~3 eV)
- Increased brightness and emission volume
- ✓ Reheating possible (2<sup>nd</sup> emission peak)
- ✓ Bonus: Low jitter trigger

#### <u>Outlook</u>

- Tomographic results for  $T_{\rm e}$  and  $n_{\rm e}$  analysis
  - $\rightarrow$  spatial temperature and density map
- FDTD-simulation with determined density and temperature distribution
- Conversion efficiency from energy calibrated spectra

#### **Metrology**

- $\checkmark$  Fast composition sensitive  $T_{e}$  and  $n_{e}$  fit
- Spectrally resolved tomographic plasma imaging
- ✓ FDTD-simulation of laser absorption in plasma



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# Thank you!

Contact: f.melsheimer@fz-juelich.de or florian.melsheimer@rwth-aachen.de



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